Advanced Materials for Applications in Extreme Environments

Symposium held November 29–December 3, Boston, Massachusetts, U.S.A.

EDITORS

Maria Samaras
Paul Scherrer Institute
Villigen, Switzerland

Chu Chun Fu
CEA Saclay
Saclay, France

Thak Sang Byun
Oak Ridge National Laboratory
Oak Ridge, Tennessee, U.S.A.

Marius Stan
Argonne National Laboratory
Argonne, Illinois, U.S.A.

Toru Ogawa
Japan Atomic Energy Agency
Naka, Japan

Arthur Motta
Pennsylvania State University
University Park, Pennsylvania, U.S.A.

David Simeone
CEA Saclay
Saclay, France

Roger Smith
Loughborough University
Loughborough, U.K.

Lumin Wang
University of Michigan
Ann Arbor, Michigan, U.S.A.

Xinghang Zhang
Texas A&M University
College Station, Texas, U.S.A.

Oliver Kraft
Karlsruhe Institute of Technology
Karlsruhe, Germany

Michael J. Demkowicz
Massachusetts Institute of Technology
Cambridge, Massachusetts, U.S.A.

Meimei Li
Argonne National Laboratory
Argonne, Illinois, U.S.A.